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Notice of Allowability	Application No.	Applicant(s)	
	10/033.408	CHEN ET AL.	
	Examiner	Art Unit	
	Shamim Ahmed	1765	
	Shaniin Ahned	1705	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.			
1. ☑ This communication is responsive to <u>10/31/03</u> .			
2. ☑ The allowed claim(s) is/are <u>1-7 and 9-55</u> .			
3. 🛮 The drawings filed on <u>26 December 2001</u> are accepted by the Examiner.			
 Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) ☐ All b) ☐ Some* c) ☐ None of the: 			
 ☐ Certified copies of the priority documents have been received. 			
2. ☐ Certified copies of the priority documents have been received in Application No			
3. Copies of the certified copies of the priority documents have been received in this national stage application from the			
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
 Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application) since a specific reference was included in the first sentence of the specification or in an Application Data Sheet. 37 CFR 1.78. 			
(a) The translation of the foreign language provisional application has been received.			
6. Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121 since a specific reference was included in the first sentence of the specification or in an Application Data Sheet. 37 CFR 1.78.			
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely compty will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.			
7. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.			
8. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.			
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached			
1) ☐ hereto or 2) ☐ to Paper No			
(b) including changes required by the proposed drawing correction filed, which has been approved by the Examiner.			
(c) 🔲 including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No			
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the margin according to 37 CFR 1.121(d).			
9. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.			
Attachment(s)	Constitution of		
1 Notice of References Cited (PTO-892)	5☐ Notice of Informal Pat	ent Application (PTO	.152)
2☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6☐ Interview Summary (P		•
3 ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/08)		/· · -	—·

NADINE G. NORTON PRIMARY EXAMINER

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7 Examiner's Amendment/Comment

8⊠ Examiner's Statement of Reasons for Allowance

Paper No. _

of Biological Material

4☐ Examiner's Comment Regarding Requirement for Deposit

9 Other

Application/Control Number: 10/033,408

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REASONS FOR ALLOWANCE

1. The following is an examiner's statement of reasons for allowance: the prior art does not teach or suggest a method of growing self-assembled nanowires on the etchable layer by forming an interfacial plane with significant lattice mismatch along all the crystallographic axes except one major axis during q process of forming nanowires as the context of claim 1.

The prior art also does not teach or suggest that the etching rate of the etchable layer is at least twice than that of the self-assembled nanowires as the context of claim 21.

The prior art also does not teach or suggest that the etching or removal rate of the self-assembled nanowires is at least twice than that of etchable layer during the selective removal of the nanowires as the context of claim 39.

2. The closest prior art Choi et al (6,440,637) disclose a step of anisotropic reactive ion etching of the etchable layer using the nano structure as a mask to form the nanowires (37a and 37b) onto a substrate and Choi et al also teach that the self-assembled nano structures (28a and 28b) are removed after forming the nanowires on the substrate (col.6, lines 19-28 and lines 25-26).

However, Choi et al fail to teach the etching rate of the etchable layer is twice than that of the nano structures or vise versa.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably

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accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Oath/Declaration

3. The supplemental oath or declaration filed 10/31/03 is acknowledged and recorded in the application. Accordingly, the objection to the oath or declaration by the examiner is withdrawn.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shamim Ahmed whose telephone number is (571) 272-1457. The examiner can normally be reached on M-Thu (7:00-5:30) Every Friday Off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine G Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

Shamim Ahmed Examiner Art Unit 1765

SA January 10, 2004

NADINE G. NORTON PRIMARY EXAMINER